

PATENT APPI

IN THE UNITED STATES PATENT AND TRADEMARK OFFI

In re the Application of

Kazuya OTA et al.

Group Art Unit: 2851

Application No.: 09/846,304

Examiner:

K. Brown

Filed: May 2, 2001

Docket No.: 104313.01

For:

APPARATUS AND METHOD FOR PATTERN EXPOSURE AND METHOD FOR

ADJUSTING THE APPARATUS

AMENDMENT UNDER 37 C.F.R. §1.111

Director of the U.S. Patent and Trademark Office Washington, D.C. 20231

Sir:

In reply to the June 17, 2002, Office Action, the period for response being extended by the attached Petition for Extension of Time, please amend the above-identified application as follows:

IN THE CLAIMS:

Please replace claim 12 as follows:

(Twice Amended) An exposure apparatus which exposes an object with 12. exposure light, comprising:

a light source in which optical components are installed and which generates said exposure light and non-exposure light having a wavelength which is different from that of said exposure light and including at least one of ultraviolet light and visible light;

an optical system disposed on an optical path through which said exposure light passes and including at least an illumination system which irradiates said exposure light onto an original;

a first sensor that receives said non-exposure light from said light source through at least a part of said optical system and output of which is used in adjustment of an

